

EOS CopperAlloy CuCrZr

Copper alloy CuCrZr has a favorable combination of electrical and thermal conductivity accompanied with good mechanical properties. This alloy achieves its optimal properties through heat treatment.

Main Characteristics:

- High productivity (10.9 mm³/s) with 80 µm layer thickness
- Moderate to high conductivity in heat treated condition together with good mechanical properties
- Chemical composition corresponding to C18150 and CW106C

Typical Applications:

- Rocket engine parts
- Heat exchangers
- → Induction coils

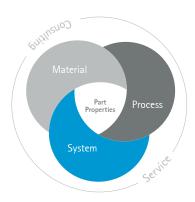
The EOS Quality Triangle

EOS uses an approach that is unique in the AM industry, taking each of the three central technical elements of the production process into account: the system, the material and the process. The data resulting from each combination is assigned a Technology Readiness Level (TRL) which makes the expected performance and production capability of the solution transparent.

EOS incorporates these TRLs into the following two categories:

- Premium products (TRL 7-9): offer highly validated data, proven capability and reproducible part properties.
- Core products (TRL 3 and 5): enable early customer access to newest technology still under development and are therefore less mature with less data.

All of the data stated in this material data sheet is produced according to EOS Quality Management System and international standards.



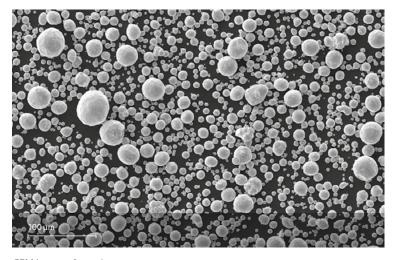
Powder Properties

Powder chemical composition (wt.-%)

Element	Min.	Max.
Cu	Ва	lance
Cr	0.45	1.15
Zr	0.05	0.25
Si	-	0.1
Fe	-	0.08

Powder particle size

Generic particle size distribution	15-75 μm



SEM image of powder

Heat Treatment

 $\label{thm:commended} Two \ different \ heat \ treatments \ are \ recommended \ for \ EOS \ CopperAlloy \ CuCrZr-one \ conductivity \ optimized \ and \ one \ tensile \ properties \ optimized.$

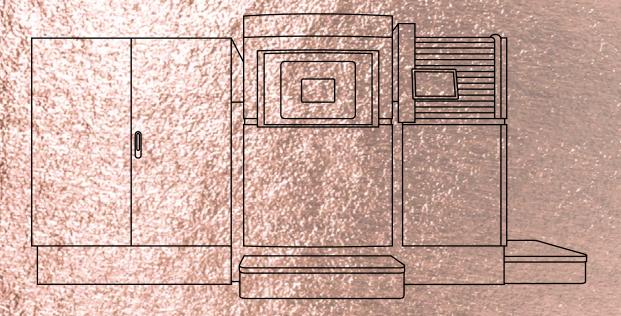
Conductivity optimized HT:

Aging: 3 h at 550 °C under inert gas flow/atmosphere. Slow cooling in inert gas until temperature is below 100 °C

Tensile optimized HT:

Aging: 1 h at in 490 °C under inert gas flow/atmosphere. Slow cooling in inert gas until temperature is below 100 °C





EOS CopperAlloy CuCrZr for EOS M 400 l 80 μm

Process Information
Physical Part Properties
Mechanical Properties
Additional Data

EOS CopperAlloy CuCrZr for EOS M400 I 80 μm





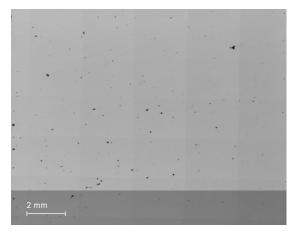
System set-up	EOS M 400-1	
EOSPAR name	CuCrZr_080_CoreM400	
Software requirements	EOSPRINT 2.11 or newer EOSYSTEM 2.15 or newer	
Powder part no.	9030-0003	
Recoater blade	HSS or Brush	
Inert gas	Argon	
Sieve	90 μm	

Additional information	
Layer thickness	80 µm
Volume rate	10.9 mm³/s
Minimal wall thickness	0.8 mm

Chemical and Physical Properties of Parts



Solid parts chemistry matches the powder chemistry



Micrograph of polished surface

Defects	Result
Average defect percentage	0.2 %
Density, ISO 3369	≥ 8.84 g/cm ³

Mechanical Properties



Typical mechanical properties

Heat treated	Yield strength R _{p0.2} [MPa]	Tensile strength R _m [MPa]	Elongation at break A [%]	Modulus of elasticity [GPa]
Horizontal Conductivity optimized HT*	345	450	21	-
Vertical Conductivity optimized HT*	330	400	24	-
Horizontal Tensile optimized HT	510	590	18	120 GPa
Vertical Tensile optimized HT	495	540	18	125 GPa

Tensile testing as per ISO 6892-1. Modulus of elasticity testing according to EN ISO 6892-1 Method A, Range 1 (0.00007 1/s).

Hardness as per ISO 6507-1	
Tensile optimized HT	190 HV10

^{*}Fewer data points were collected for the conductivity optimized heat treatment, resulting in a lower TRL of 3.

Additional Data



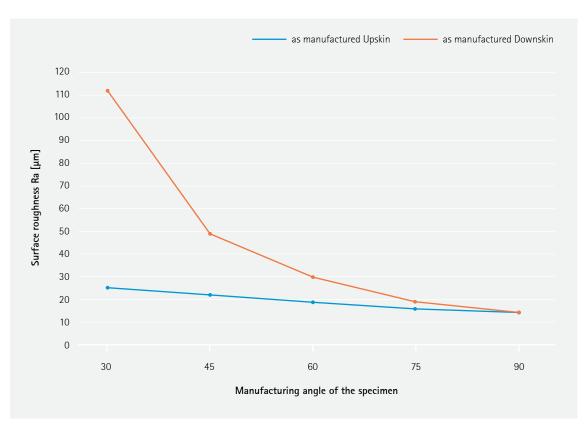
Electrical conductivity

According to ASTM E1004-17	Result	Samples
Heat treated - Conductivity optimized	85 %IACS	1 sample cube, measured from 5 surfaces
Heat treated - Tensile optimized	76 %IACS	3 sample cubes, all measured from 5 surfaces
As manufactured	23 %IACS	1 sample cube, measured from 5 surfaces

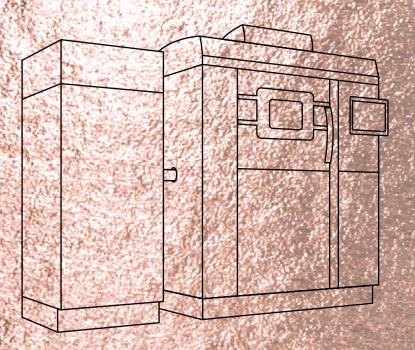
Coefficient of thermal expansion

Standard			ASTM E228			
Temperature	25-100 °C	25-200 °C	25-300 °C	25-400 °C	25-500 °C	25-600 °C
СТЕ	15.9*10 ⁻⁶ /K	17.3*10 ⁻⁶ /K	17.7*10 ⁻⁶ /K	17.3*10 ⁻⁶ /K	16.9*10 ⁻⁶ /K	17.1*10 ⁻⁶ /K

Surface Roughness







EOS CopperAlloy CuCrZr for EOS M 290 1kW l 80 μm

Process Information
Chemical and Physical Part Properties

EOS CopperAlloy CuCrZr for EOS M 290 1kW & AMCM M 290 1kW l 80 μm



Process Information

EOS M 290 1kW	AMCM M 290 1kW	
CuCrZr_080_CoreM294	CuCrZr_080_CoreM291_1kW_100	
EOSPRINT 2.15 or newer EOSYSTEM 2.19 or newer	EOSPRINT 2.7 or newer EOSYSTEM 2.11 or newer	
9030-0003		
HSS		
Argon		
90 μm		
	CuCrZr_080_CoreM294 EOSPRINT 2.15 or newer EOSYSTEM 2.19 or newer 9030 H	

Additional information	
Layer thickness	80 µm
Volume rate	15.4 mm³/s

Chemical and Physical Properties of Parts



Solid parts chemistry matches the powder chemistry

Defects	Result
Average defect percentage	0.2 %
Density, ISO3369	≥ 8.84 g/cm ³



Micrograph of polished surface

Typical part properties

Heat treated	Yield strength R _{p0.2} [MPa]	Tensile strength R _m [MPa]	Elongation at break A [%]	Conductivity
As manufactured	160	210	40	> 20 % IACS
Heat treated	210	340	25	> 80 % IACS

Tensile testing as per ISO 6892-1. Conductivity tested acc. ASTM E1004-17.

Status 01/2025

EOS is certified according to ISO 9001. EOS®, DMLS® and EOSPRINT® are registered trademarks of EOS GmbH in some countries. For more information visit www.eos.info/trademarks.

Cover: This image shows a possible application.

Important Note

This data sheet specifies the powder properties of the EOS powder type referenced above. If you purchase powder from EOS, EOS will deliver suchpowder in conformity with the version of this data sheet prevailing at the time of your order. If you purchase powder from any source other than EOS, EOS makes no warranties or representations with respect to powder properties to you whatsoever, and claims with respect to the quality or properties of EOS powder are available only against the seller of such powder in accordance with your agreement with the seller, not against EOS.—EOS data sheets are subject to change without notice. This data sheet does not constitute a guaranty or warranty of properties or fitness for a specific purpose and may not be relied upon as such.

Part properties stated above are provided for information purposes only and EOS makes no representation or warranty whatsoever, and disclaims any liability, with respect to actual part properties achieved with this material. Part properties are subject to variation and dependent on factors such as system parameters, process and test geometries. Therefore actual part properties may deviate and users of this material are exclusively responsible to determine its suitability for the intended use. The part properties stated above have been determined by testing this material with above specified type of EOS Laser Powder Bed Fusion system, EOSYSTEM and EOSPRINT software version, parameter set and operation in compliance with parameter sheet and operating instructions. Part properties are measured with specified measurement methods using defined test geometries and procedures. Further details of the test procedures used by EOS are available on request.

Headquarters

www.eos.info

EOS GmbH Electro Optical Systems Robert-Stirling-Ring 1 D-82152 Krailling/Munich Germany Phone +49 89 893 36-0 info@eos.info

Further Offices

#futureisadditive

EOS France Phone +33 437 497 676

EOS Greater China Phone +86 21 602 307 00

EOS India Phone +91 443 964 8000

EOS Italy Phone +39 023 340 1659

EOS Japan Phone +81 45 670 0250

EOS Korea Phone +82 2 6330 5800

EOS Nordic & Baltic Phone +46 31 760 4640

EOS of North America Phone +1 877 388 7916

EOS Singapore Phone +65 6430 0463

EOS UK Phone +44 1926 675 110

